Supplementary Information

Enhancement of Electrochromic Properties Using Nanostructured Amorphous Tungsten Trioxide Thin Films

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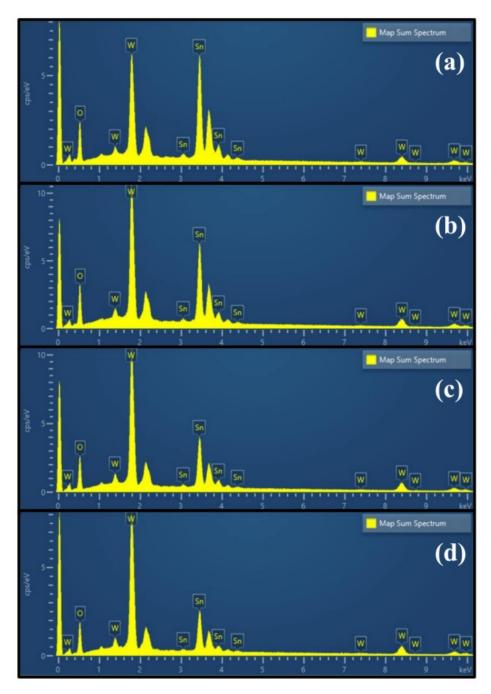


Fig. S1. EDS spactra of the (a) $pH1.8WO_3$, (b) $pH1.6WO_3$, (c) $pH1.4WO_3$, and (d) $pH1.2WO_3$

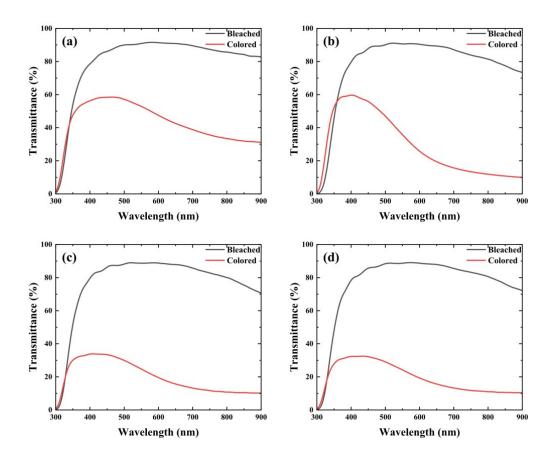


Fig. S2. Transmittance spectra of the WO3 films (a) $pH1.8WO_3$, (b) $pH1.6WO_3$, (c) $pH1.4WO_3$, and (d) $pH1.2WO_3$ measured at -1V (colored state) and 1V (bleached state) between the wavelength range of 300 and 900nm.